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X-ray diffuse scattering from a nitrogen-implanted niobium film

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A 2500-Å niobium single-crystal film was deposited onto a sapphire substrate and subsequently implanted with nitrogen to an average concentration of 0.5 at. %. Synchrotron radiation was used to measure the difference between the implanted and an unimplanted film to isolate the diffuse scattering from the implanted film near two Bragg reflections. This diffuse intensity arises mainly from elastic displacement fields about radiation-damage-related loops located on (211) planes. A small contribution of the scattering is calculated from the displacements about single interstitial nitrogen in octahedral sites. The Burgers vector of the loops is along the [111] direction and makes an angle of 62° with the loop plane giving a dominant shear component. Vacancy loops have a radius ~5 Å while interstitials are somewhat larger ranging from 10 to 15 Å. The number of vacancies and interstitials are nearly the same.

I. INTRODUCTION

The structure of ion-implanted zones at high concentrations is complex and not well known. X-ray diffraction offers the possibility of examining zones nondestructively under the same stress conditions as the original implanted samples. Internal sources of stress can arise from the stress field of the implants themselves, as well as from knock-on defects produced by the energetic ions. To understand these two sources, further information is required about the atomic configurations of the stress-producing defects.

Under equilibrium conditions, N atoms become located at three equivalent octahedral positions in Nb. This produces a major expansion of two first-neighbor lattice atoms along the c direction, and a smaller contraction of four second-neighbor lattice atoms. This sizeable core disturbance produces lattice displacements like the highly anisotropic displacement field about a carbon atom in a bcc Fe lattice. Locating the c axis along three mutually perpendicular directions, maintains the overall cubic symmetry of the lattice.

Electron microscopy of thinned (stress relieved) samples shows the presence of small vacancy and self-interstitial loops ranging from 5 to 15 Å (Refs. 3 and 4) after neutron irradiation of Nb and Mo. It has been shown that for Ni-implanted Cu at liquid-He temperature, (LHT) these sources of internal stress almost cancel except for a stress contribution from the core region, i.e., near the circumference of the loop. Both N interstitials and loops produce local displacements that decrease the integrated intensity of the Bragg peaks. This decrease may be associated with the appearance of diffuse scattering which is the primary focus of this paper.

X-ray intensity band analysis of N, implanted at liquid-nitrogen temperature (LNT) to an average of 5 at. %, revealed the presence of high biaxial compressive stresses along the implanted zone. Evidence for some pointlike defects and defect clusters was obtained from attenuation studies of pointlike defects and loop defects. The displacement field from a loop is obtained from calculations by Ohr. In this paper, x-ray diffuse scattering was measured about the (330) and (222) from a 2500-Å Nb crystal film oriented with the (111) plane parallel to the free surface. The N implantation resulted in an average concentration of 0.5 at. % N and ~6 major displacements per atom (dpa). At this lower concentration, the line broadening from the nonuniform d spacing was small enough to enable diffuse scattering to be measured close to the Bragg peaks. This is very weak for a film and required synchrotron radiation with relatively long counting times. Scattering calculations were based upon the elastic field from vacancy and interstitial loops, as well as implanted N, located in octahedral sites distributed equally over the three equivalent sites. Brief discussions of these results have been published in conference proceedings.

II. THEORY

The primary equations given here, describing x-ray diffuse scattering from dislocation loops in cubic crystals, may be found in Refs. 5 and 6. The intensity of diffuse scattering from randomly distributed defect clusters, in the single-defect approximation, is given by

\[ I_{\text{diff}}(H) = N_P r_e f^2 |A(H)|^2, \]

where \( r_e \) is the classical electron radius, \( f \) is the atomic scattering factor of the host lattice, \( H = h_1b_1 + h_2b_2 + h_3b_3 \) is the x-ray scattering vector, \( N_P \) is...
is the total number of defect clusters, and \( A(H) \) is the scattering amplitude of the defect cluster which for a dislocation loop can be written as\(^\text{5,6}\)

\[
A(H) = \sum_D \exp((2\pi i R_D H^P) + \sum_n \exp((2\pi i R^n H^n)) \\
\times [\exp((2\pi i R^n - u^n)] - 1].
\]  

The first sum is over the atoms in the loop situated at positions \( R_D^P \) and the second sum ranges over the atoms in the host lattice situated at positions \( R^n - R^P + u^n \), where \( u^n \) is the displacement of the \( n^{th} \) atom relative to the regular periodic lattice position \( R^n \), due to the loop, \( \Delta H = H - H^P \), where \( H^P \) is the reciprocal lattice vector, \( h^P + k^P + l^P \), and \( h, k, \) and \( l \) are the Miller indices of the Bragg reflection. The Huang term is separated from the second term in Eq. (2) in the usual way:

\[
A(H) = \sum_D \exp((2\pi i R_D H^P) + \sum_n \exp((2\pi i R^n H^n)) \\
2 \exp((2\pi i R^P H^P)) + i2n-H.u(2rAH) \\
+ 1 \exp((2\pi i R^P H^P)) \exp((2\pi i R^P H^P) - 1 - 2rAH.u), \tag{3}
\]

in which \( u(2\pi i H^P) \) is the Fourier-transformed displacement field. The scattering amplitude of Eq. (3) can be written as five separate components:

\[
A(H) = A_1^S(H) + A_2^S(H) + A_3^S(H) + A_1^A(H) + A_2^A(H), \tag{4}
\]

where

\[
A_1^S(H) = \frac{\pi R_D^P b_n J_1(2\pi i R_D H^P R_0)}{V_c} \frac{Q}{(2\pi i R_D H^P R_0)}, \tag{5a}
\]

\[
A_2^S(H) = -\frac{4\pi^2 T^P G_{nm} \Delta H m J_1(2\pi i R_D H^P R_0)}{V_c} \frac{2J_1(2\pi i R_D H^P R_0)}{2\pi i R_D H^P R_0}, \tag{5b}
\]

\[
A_3^S(H) = -\frac{4\pi^2 \Delta H m G_{nm} \Delta H m J_1(2\pi i R_D H^P R_0)}{V_c} \frac{2J_1(2\pi i R_D H^P R_0)}{2\pi i R_D H^P R_0}, \tag{5c}
\]

\[
A_3^S(H) = \frac{1}{V_c} \int_R \cos(2\pi i R^P H^P) \cos(2\pi i R^P H^P) - 1 dR, \tag{5d}
\]

and

\[
A_3^A(H) = -\frac{1}{V_c} \int_R \sin(2\pi i R^P H^P) \sin(2\pi i R^P H^P) - 2\pi i R^P H^P u^P dR. \tag{5e}
\]

In deriving Eqs. (4) and (5a–5e) from Eq. (3), the lattice sums were written as integrals.\(^\text{5,6}\) Einstein’s summation convention is implied in Eqs. (5b) and (5c).\(^\text{13}\) In Eqs. (5), \( b_n \) is the Burgers vector component perpendicular to the loop plane. \( R_0 \) is the radius of the circular loop. \( V_c \) is the volume of a lattice atom. \( J_1 \) is the Bessel function of order 1, \( \Delta H^P \) is the projection of \( \Delta H \) on to the loop plane, \( \Phi \) is the phase factor for direct scattering from the loop which is +1 for interstitial loops and -1 for vacancy loops. \( G_{nm} \) is the Fourier transform of the elastic Green’s function written in the cubic coordinate system, i.e.\(^\text{6}\)

\[
G_{nm}(2\pi i \Delta H) = \frac{1}{(2\pi i |\Delta H|)^2} \left( \frac{\delta_{ln}}{(C_{44} + C_{\text{att}} e_n)} - \frac{e_n e_m}{(C_{44} + C_{\text{att}} e_n)(C_{44} + C_{\text{att}} e_m)} \right) \\
\times \{1 + \Sigma_{k,l}[(C_{44} + C_{12})/(C_{44} + C_{\text{att}} e_k)] e_{k,l}^2\}, \tag{6}
\]

where \( \delta_{ln} \) is the Kronecker delta function. \( P_{nm} \) is the dipole force tensor for the loop in the cubic system. It is evaluated from the area vector and Burgers vectors \( b \), of the loop:

\[
P_{nm} = (C_{12} Tr \omega_{nm} + C_{\text{att}} \omega_{nm}) \delta_{nm} + 2C_{44} \omega_{nm}, \tag{7}
\]

where \( \omega_{nm} = \frac{1}{2}(S_{n,b_m} + S_{m,b_n}) \). The subscripts \( n,m \) designate vector components. \( Tr \omega_{nm} = \Sigma_{\omega_{nm}} \) are defined in the cubic coordinate system. In Eq. (7), Einstein’s summation convention is not implied.

The superscripts \( S \) and \( A \) in Eq. (4) refer to symmetric and antisymmetric components with respect to the deviation in the scattering vector from the reciprocal lattice point \( \Delta H \). The first term [Eq. (5a)] is the direct Laue scattering from the loop, the next two terms are the symmetric and antisymmetric components of the Huang scattering amplitude [Eqs. (5b) and (5c)] and the last two terms [Eqs. (5d) and (5e)] are the scattering from the displaced atoms close to the loop which have to be evaluated numerically. The last two terms are symmetric and antisymmetric only if \(|\Delta H| < |H^P|\). At very low \( \Delta H \) values, \( A_2^S(H) \) goes to zero and \( A_3^A(H) \) goes to zero and \( A_3^A(H) = M/C^2 \), where \( M \) is the attenuation factor associated with the distortions around the loop and \( C \) is the atomic fraction of loops. Therefore, for very low \( \Delta H \) values, the diffuse scattering is influenced only by the Laue scattering, Huang scattering, and the attenuation factor.

### III. NUMERICAL CALCULATIONS

Equations (5a), (5b), and (5c) can be readily evaluated for any loop orientation and any combination of \( H^P \) and \( \Delta H \). The amplitudes \( A_1^S(H) \) and \( A_2^S(H) \) have to be evaluated numerically. For the present purposes, three types of loops were considered, (110) [111], (211) [111], and (110) [100]. Electron microscopy studies of neutron-irradiated Mo and Nb have shown that the predominant irradiation-induced defects are dislocation loops having their Burgers vector along the [111] or [100] directions, with a large shear component.\(^\text{3,4}\) Prismatic faulted dislocation loops are not prevalent in irradiated bcc metals, presumably because of the high stacking fault energy in these metals.\(^\text{3}\) Unfortunately, electron microscopy studies are ambiguous as to the exact orientation of the loop plane.\(^\text{3}\) The \( z \) axis was selected perpendicular to the plane of the
loop and the displacements are written in terms of rectangular coordinates, with

\[ u_1(Z/R_0, \rho/R_0 \phi), \quad u_2(Z/R_0, \rho/R_0 \phi), \]

and

\[ u_3(Z/R_0, \rho/R_0 \phi), \]

in units of the Burger’s vector. They were evaluated for a cylindrical grid of points with \( \Delta \rho = \Delta Z = R_0/10, \Delta \phi = \pi/10 \). The displacements were evaluated using the formula given by Ohr,\textsuperscript{12}

\[ u_i(R/R_0) = \frac{R_0}{4\pi N} \int_0^{2\pi} \left[ \sum_{j=1}^N \left( \frac{R}{R_0} \right)^2 F_i(\chi_i) \right] d\theta \]  

(8)

where

\[ \chi_i = \left[ (\cos \theta) \hat{\tau} + (\sin \theta) \hat{\tau} + t_j \hat{k} \right] / \sqrt{1 + t_j^2} \]

and

\[ t_j = (b + a)/2 + (b - a) \cos[(2j - 1)\pi/2N]/2. \]

The Burger’s projection onto the (211) plane also defines the direction of the x axis of this figure. Figure 3 is a scaled diffuse scattering plot illustrating the influence of loop orientation and the direction of the Burger’s vector projected onto the (211) plane with a Burger’s vector \( a/2 \) [111]. The Burger’s vector projected onto the (211) is along the x axis of this figure.

(9)

The amplitudes \( A_s^*(H) \) and \( A_s^*(H) \), were calculated by numerically evaluating the integrals given in Eqs. (5d) and (5e) over a cylindrical volume bounded by \( \rho = 5R_0 \), \( z = 10R_0 \) around the circular loop. The contribution from atoms situated beyond \( \rho = 5R_0 \), \( z = 10R_0 \) to the amplitudes \( A_s^*(H) \) and \( A_s^*(H) \) is negligible. Intensities are calculated from an equally weighted average over all equivalent loop orientations, such that the cubic symmetry of the crystal is maintained. It is seen that the intensities are much larger in the transverse direction, as compared to the radial directions. In addition, for vacancy loops, there is a large directional dependence in the diffuse scattering along the radial directions from the reciprocal lattice point (i.e., the scattering along the [110] direction is much smaller than along the [110] direction). The intensity plots from interstitial loops are very similar, but the intensities along the radial directions are reversed (i.e., the scattering along the [110] direction is much smaller than along the [110] direction). The scaled diffuse scattering show a distinct structure with maxima, that shift closer to the Bragg peak position with increasing radius of the loop. The shift approximately scales as \( 1/R_0 \). Note that the results are very similar to the ones obtained by Larson and Young\textsuperscript{5} in their diffuse scattering simulations from prismatic dislocation loops in face centered cubic metals. They are explained in terms of Bragg scattering from almost constant strain regions within one radius of the loop.\textsuperscript{5,14} A measurement of diffuse scattering around the (330) reciprocal lattice point along both the radial and transverse direction allows one to determine the type (vacancy or interstitial), concentration, and size distribution of loops. Figure 3 is a scaled \( (x [2\pi \Delta H]^4 \) diffuse scattering plot illustrating the influence of loop orientation and the direction of the Burger’s
FIG. 2. Scaled theoretical diffuse scattering curves around the (330) along three designated directions. The loop plane is (211) and the Burger's vector is a/2 [110]. 5-, 10-, and 15-Å loops are illustrated. Multiply Y axis by 1.2×10^4 to obtain electron units per atoms/nm^4.

FIG. 3. Scaled theoretical diffuse scattering curves around the (330) along three designated directions. The loop plane and Burger's vector are as indicated in (a), (b), and (c). 10-Å radius vacancy loops are used for all three. Multiply Y axis by 1.2×10^4 to obtain eua/nm^4.

vector for three common arrangements. Each configuration has a unique plot. We find that (211)[111]-type loops are the predominant defects.

IV.EXPERIMENTAL DETAILS

Two single-crystal films having a (111) orientation and a thickness of 2500 Å were deposited onto (001) sapphire substrates at the Naval Research Laboratory using a vacuum of better than 10^-10 Torr. For the x-ray diffuse scattering measurements, one of the films was used as an unimplanted standard and the other was implanted with N to an average concentration of 0.5 at. % at LNT using a four-step implantation process. The implantation sequence is shown in Table I beginning with the highest energy followed by successively lower energies. The Gaussian-like distributions become sharper at the lower energies, and are designed to superimpose with roughly a constant composition of N. The uniformity of this distribution has been examined in Ref. 7. The maximum damage energy in the implanted film produced 6 dpa.

Diffuse scattering measurements were made at the NSLS with synchrotron radiation with a wavelength of 0.8835 Å. Data were collected near the (330) peak along the radial [110], [110] directions and [110][110] transverse directions. The transverse directions [211], [211], and [110] directions were used to obtain data about the (222). Approximately 200 000 counts were required at each point to obtain statistically reliable results. Background from temperature diffuse and Compton scattering were removed by taking a difference between implanted and unimplanted samples giving an average of 10 000 counts per point. An absolute intensity scale was obtained using the integrated

<table>
<thead>
<tr>
<th>Energy (eV)</th>
<th>Range (Å)</th>
<th>Standard deviation (Å)</th>
<th>fluence/atoms/Å²</th>
</tr>
</thead>
<tbody>
<tr>
<td>190</td>
<td>2094</td>
<td>729</td>
<td>0.49</td>
</tr>
<tr>
<td>89</td>
<td>1076</td>
<td>463</td>
<td>0.20</td>
</tr>
<tr>
<td>43</td>
<td>559</td>
<td>275</td>
<td>0.12</td>
</tr>
<tr>
<td>17.5</td>
<td>259</td>
<td>141</td>
<td>0.055</td>
</tr>
</tbody>
</table>
FIG. 4. Scaled experimental diffuse scattering from loops and theoretical fits about (330) along three designated directions. Parameters may be found in Table I. Multiply Y axis by $1.2 \times 10^4$ to obtain $\text{eV} \text{/nm}^4$.

FIG. 5. Scaled theoretical diffuse scattering about (330) along three designated directions for the displacements from 0.5 at. % N in Nb. Multiply Y axis by $1.05 \times 10^4$ to obtain $\text{eV} \text{/nm}^4$.
The concentrations of vacancy and interstitial loops of different radii, per cm$^3$, and the total amount of point defects in loops, in a (111) single-crystal Nb film implanted with N to an average concentration of 0.5 at. %.

<table>
<thead>
<tr>
<th>Radius (Å)</th>
<th>$c_{vaxi}$/cm$^3$ $\times 10^{-18}$</th>
<th>$c_{vaxi}$/cm$^3$ $\times 10^{-19}$</th>
<th>$N_v$ (at. %)</th>
</tr>
</thead>
<tbody>
<tr>
<td>5</td>
<td>...</td>
<td>1.09</td>
<td>0.115</td>
</tr>
<tr>
<td>10</td>
<td>1.64</td>
<td>...</td>
<td>0.069</td>
</tr>
<tr>
<td>15</td>
<td>0.221</td>
<td>...</td>
<td>0.021</td>
</tr>
</tbody>
</table>

The ratio of the magnitude of experimental diffuse scattering along the transverse to the radial directions is $\sim 3$ (see Fig. 4), indicating that (211)[111] loops are the predominant defect clusters and (011)[111] and (011)[001] loops are not prevalent in the implanted sample (see Fig. 3). A linear least-squares fit of the experimental data with respect to the concentration of (211)[111] vacancy and interstitial loops of sizes 5, 10, and 15 Å is shown in Fig. 4. The concentrations of vacancy and interstitial loops per unit volume, of radii 5, 10, and 15 Å, obtained from the linear least-squares fit is given in Table II. Table II also gives the concentration of single vacancies and interstitials retained in the implanted sample which are located in loops.

Additional data were collected to confirm the results of Table II. Figure 6 shows the experimental diffuse intensity around the (222) reflection averaged over the two symmetrical transverse directions, [112], and [112]. The overall agreement between theory and experiment is shown for (211)[111] and (110)[111] loops. Again, one finds the best agreement with (211)[111] loops.

Vacancy loops are predominantly 5 Å in radius, whereas the interstitial loops are distributed over the range 10–15 Å. Interstitial loops are expected to be larger in size as compared to vacancy loops, because of the higher mobility of self-interstitials as compared to vacancies. This size difference has been found after several types of irradiations into Cu. The ratio of the total number of vacancies to total number of interstitials, retained in the implanted sample, in loops, would seem to indicate that self-interstitials are lost at sinks such as dislocations or interfaces, which are present in the unimplanted sample. However, the total concentration of single vacancies in the irradiated film, in loops, is 0.11 at. % and for single interstitials, 0.095 at. %. This small difference is within the error of our analysis.

Attenuation factor data, obtained from the reduction of the integrated intensities, is in agreement with the proposed loop model and with N located in octahedral positions. This agreement, using the data of the preceding paragraph as well as the N level already cited for the 0.5-at. % sample, represents additional confirmation of the simple model for N implanted into Nb. Our results for the implanted Nb films are similar to the ones obtained in Ref. 5, for neutron and ion irradiations of single crystal Cu at 4 K and a lower damage energy. In both cases, loops of small size are found with nearly the same number of interstitials and vacancies. The major difference between our results and the previous results is that the average radius of the loops is approximately $\frac{1}{2}$ of what was found in irradiated Cu. One difference may be associated with the high stacking fault energy in bcc metals which results in the formation of unfaulted loops with a large shear component. These x-ray measurements do not unambiguously establish that the vacancy-type clusters are dislocation loops, particularly if one considers the small size of the loops. However, the presence of similar scattered intensity at negative $\Delta H$ values in Fig. 4 does establish that the total collapsed volume is essentially equal to the interstitial loop volume.

**VI. CONCLUSIONS**

The following conclusions have been reached.

(i) X-ray diffuse scattering from a 2500 Å, (111) single-crystal Nb film, implanted to 0.5 at. % N at LNT, arises predominantly from damage-related clusters formed during the irradiation process.

(ii) The damage-related clusters are identified to be (211)[111]-type vacancy and interstitial loops. Vacancy loops have predominantly a 5-Å radius. The interstitial loops are of larger radii, i.e., 10–15 Å. The data were fitted with 75% of the interstitials retained as 10-Å loops and 25% as 15 Å loops. The total amount of vacancies or interstitials retained in the film in loops were found to be $\sim 0.10$ at. %.

![Fig. 6](https://example.com/fig6.png)
ACKNOWLEDGMENTS

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